

L Number	Hits	Search Text	DB	Time stamp
1	12	"6038279"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 15:43
2	1	mask same resist same collimator same stage and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 15:48
3	30	mask same collimator same stage and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 15:53
4	1	378/35 and collimator same stage and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 15:54
5	11	378/34 and collimator same stage and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 15:56
6	53	378/34 and collimator and stage	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 16:23
7	102	378/34 and collimator	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 16:15
8	38	378/34 and collimator and stage and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 16:32
9	79	378/34 and collimator and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 17:21
10	5	exposing same resist same collimator and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 17:03
11	13	exposing and resist same collimator and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 17:08
12	12	exposing and resist same collimator and x-ray and mask	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 17:13

13	32	exposing same collimator and x-ray and mask	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 17:13
14	302	lithography and collimator and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 17:22
15	48	lithography same collimator and x-ray	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/08/31 17:22